Advances in SiC Power Technology

DARPA MTO Symposium

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Cree, Inc.

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Standard Form 298 (Rev. 8-98)
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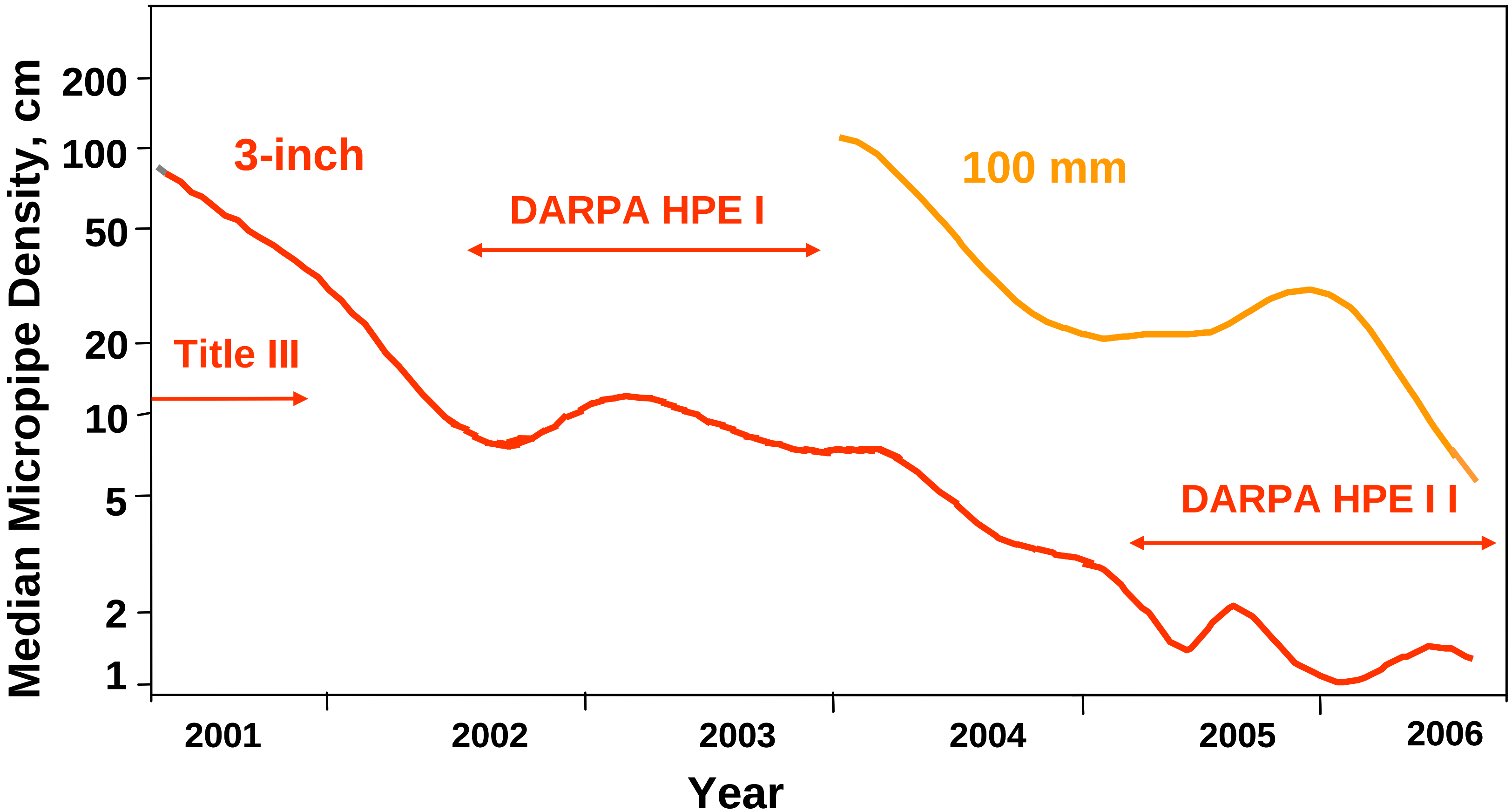
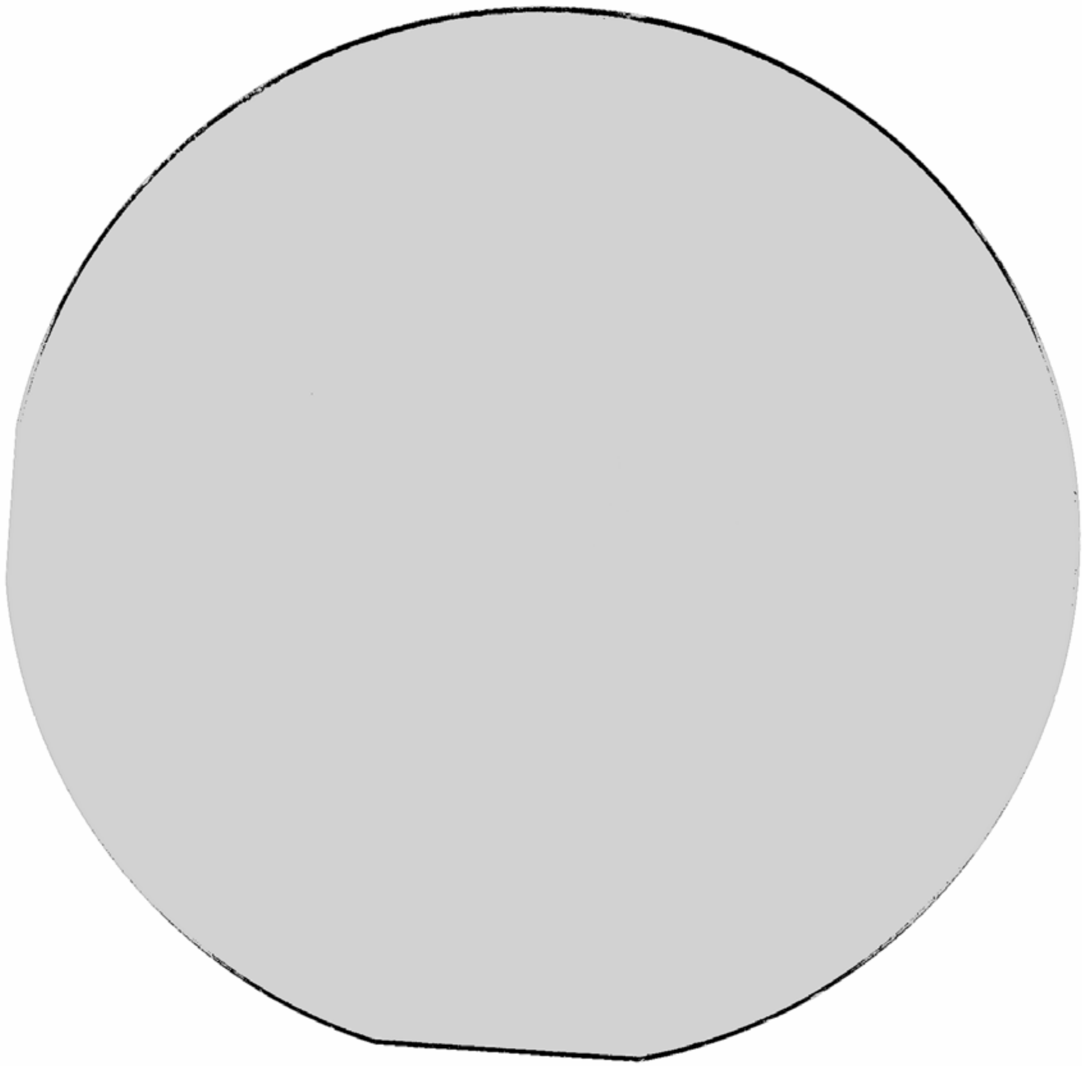
Monthly Median Production MPD



100-mm work supported by ARL MTO (W911NF-04-2-0021) and DARPA (N00014-02-C-0306)

3-inch 4HN SiC Wafer Production Process Quality

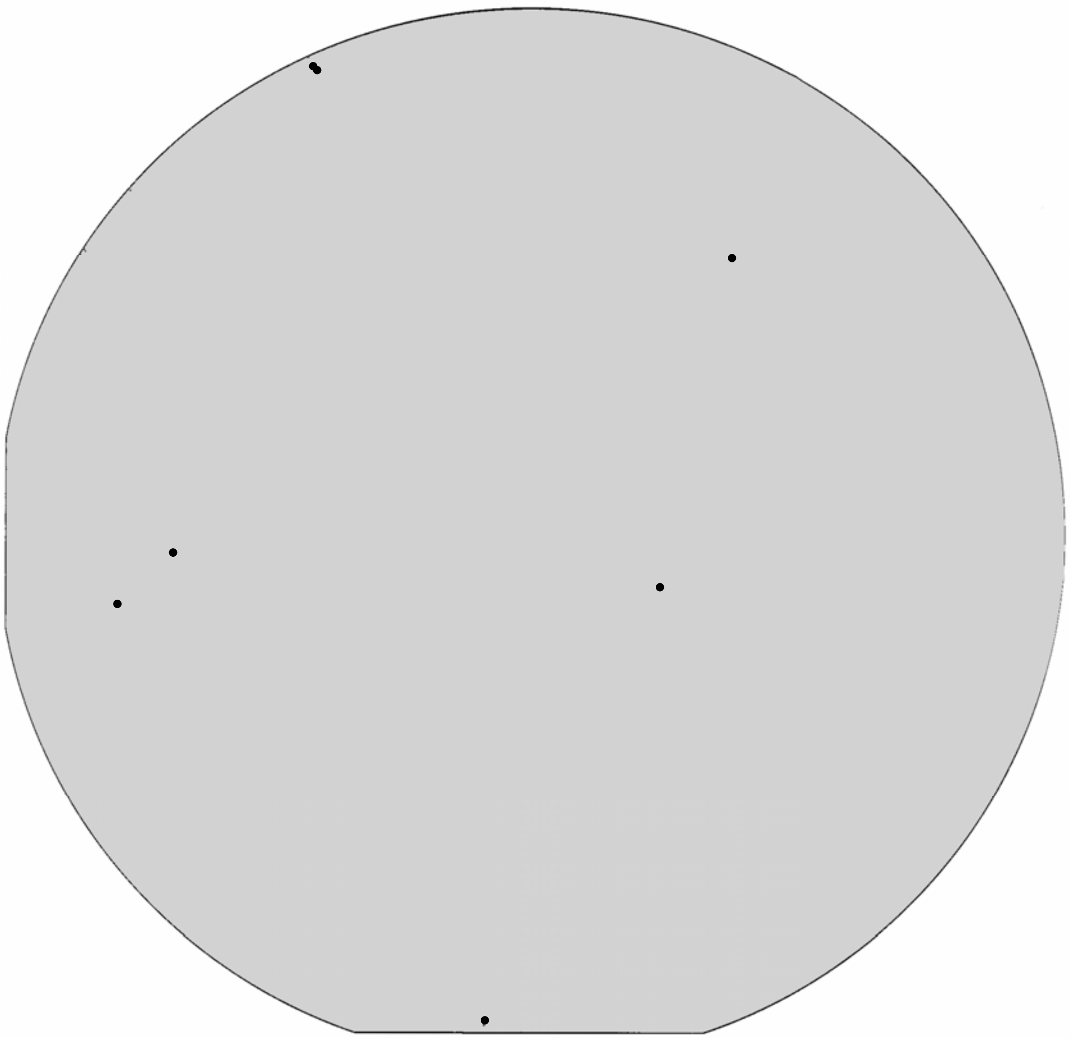


- **Best Production 3-inch 4HN SiC wafer MPD = 0.02 cm^{-2}**

- **Best R&D 3-inch 4HN SiC Wafer MPD = 0.00 cm^{-2}**

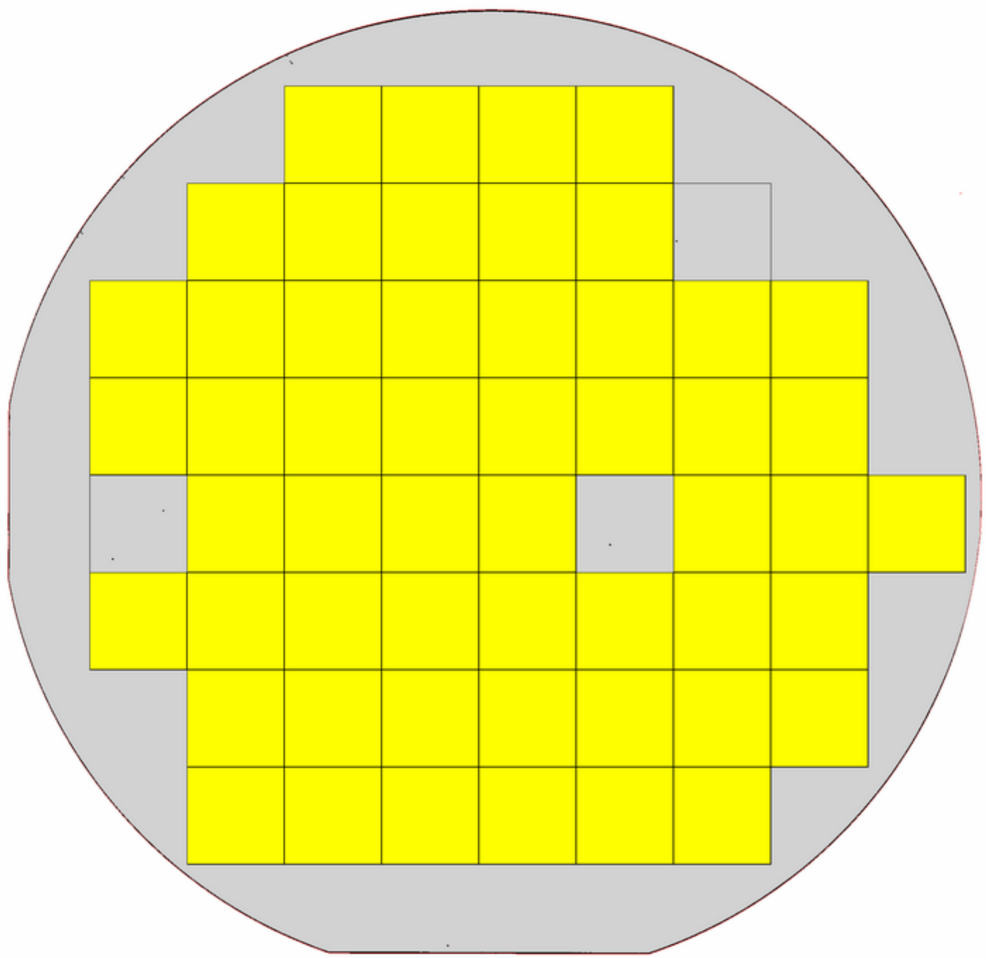
ZMP

100 mm 4HN-SiC Wafer Production Process Quality



- Almost Double the Area of a 3-inch 4HN-SiC Wafer
- Lowest MPD for 100 mm 4HN-SiC With MPD = 0.1 cm^{-2}
- Median MPD < 5 cm^{-2} in Production Process

Projected Device Yield From Lowest MPD 100 mm Wafer Thus Far

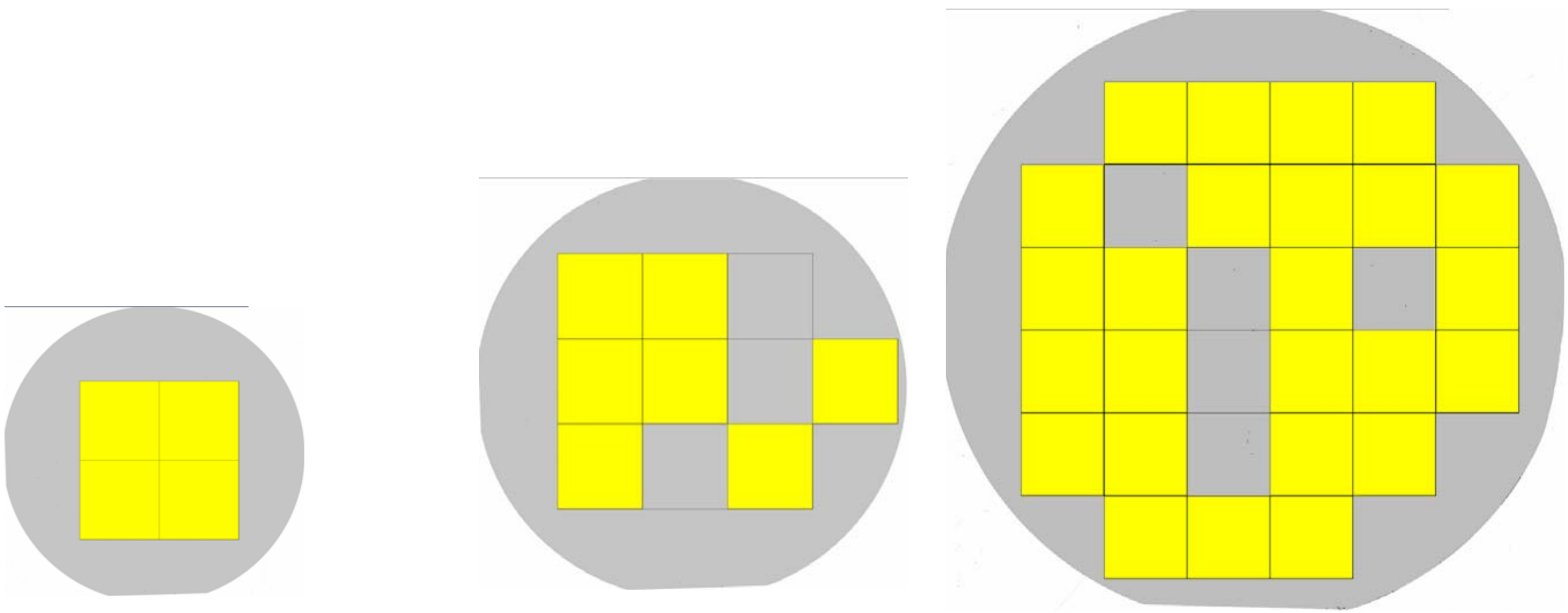


- **Projected Yield for 1 cm^2 Devices**
- **Assume Device Failure Only From Micropipes**

- **Micropipe Density = 0.1 cm^{-2}**
- **Projected Device Yield > 94%**
- **Yielded Devices = 53**
- **65% More Devices Than Ideal 3-inch 4HN SiC Wafer**

Decreasing Cost of SiC Devices by Scaling Up 150mm Wafers

Projected Impact ⇒ > 6X More 4 cm^2 Devices on 150 mm 4HN SiC Wafer

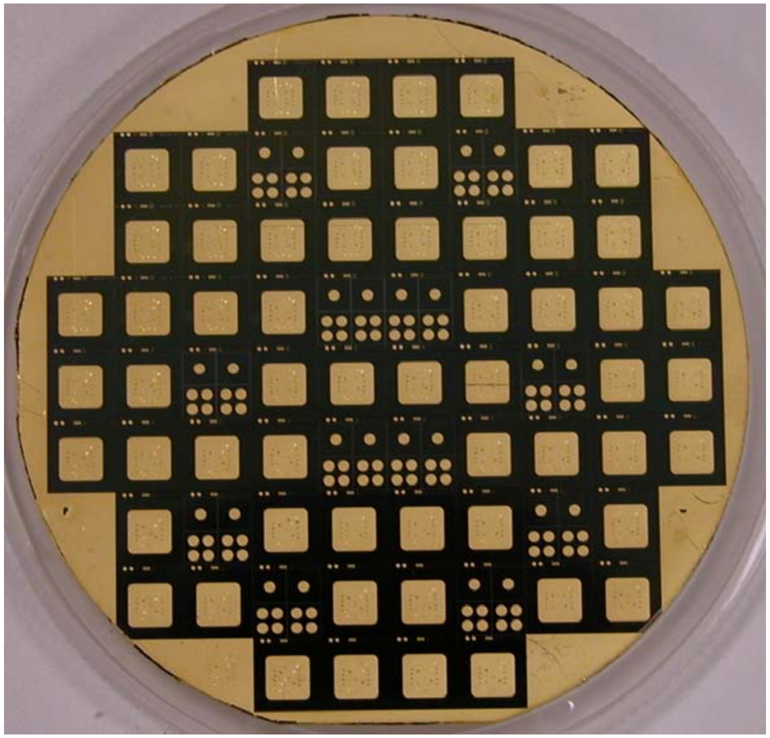


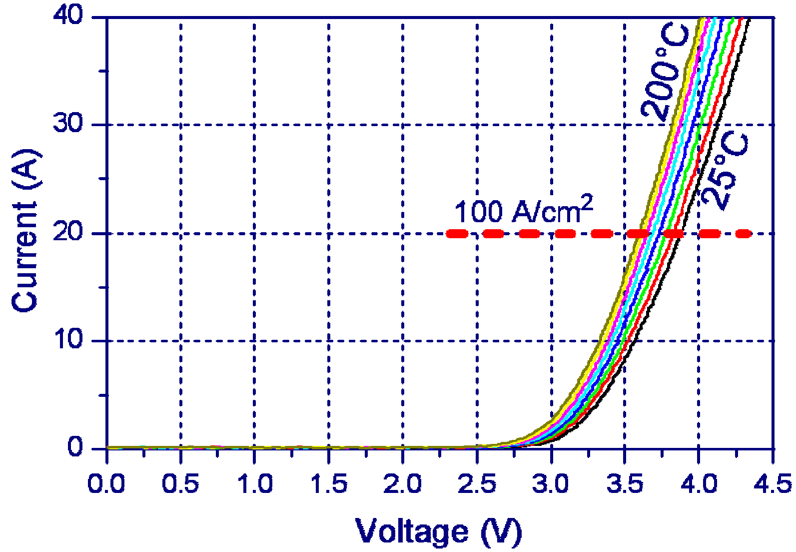
3-inch 4HN-SiC Wafer
ZMP Wafer MPD = 0 cm^{-2}
4 cm^2 device yield = 100%
Yielded 4 cm^2 devices = 4

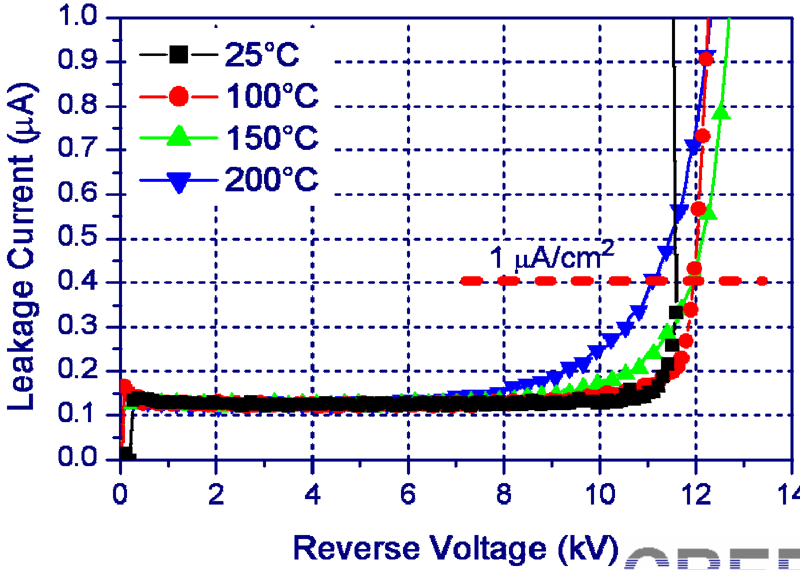
100 mm 4HN-SiC Wafer
Wafer MPD = 0.20 cm^{-2}
4 cm^2 device yield = 70%
Yielding 4 cm^2 devices = 7

Projected 150 mm 4HN-SiC Wafer
Estimated MPD = 0.20 cm^{-2}
4 cm^2 device yield = 83%
Yielding 4 cm^2 devices = 25

10kV/20A SiC PiN Diode Characteristics Up to 200ºC

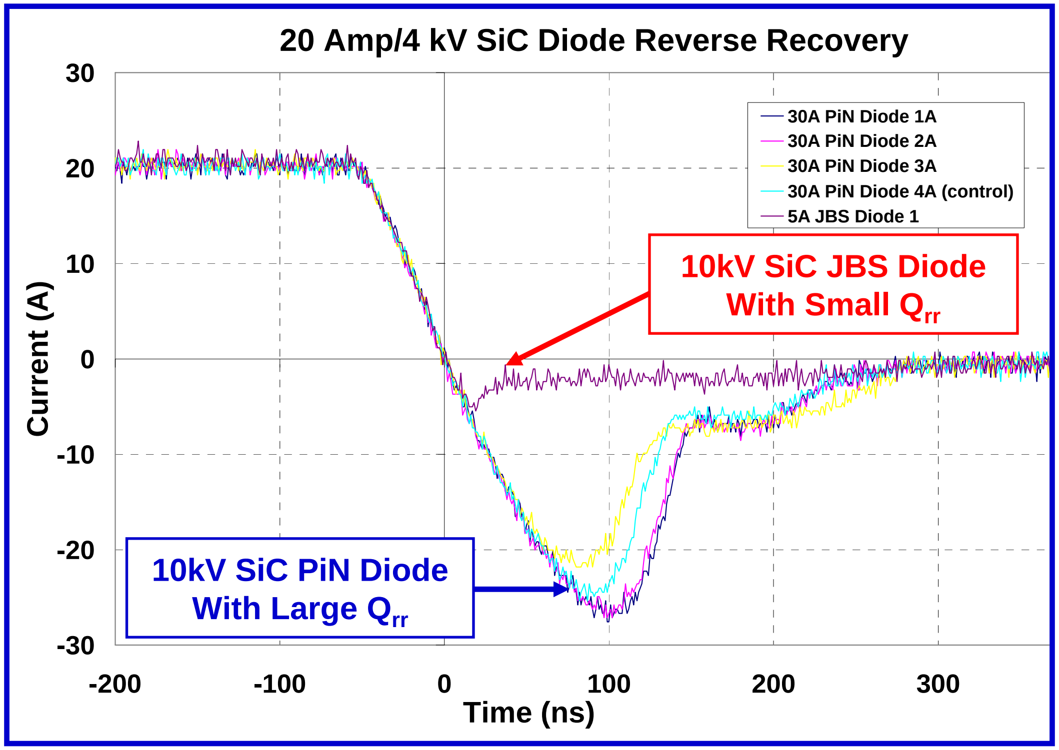






- **10kV/20A SiC PiN Diode**
  - **V_F = 3.87 at 25°C**
  - **V_F = 3.60 at 200°C**
  - **V_{BR} > 11.5 kV**
  - **I_R < 300 nA at 10 kV & Tj = 200°C**
- **Total SiC PiN Diode Yield ~ 40%**

10kV SiC JBS Diode Demonstrated For 20 kHz Switching of SiC Module

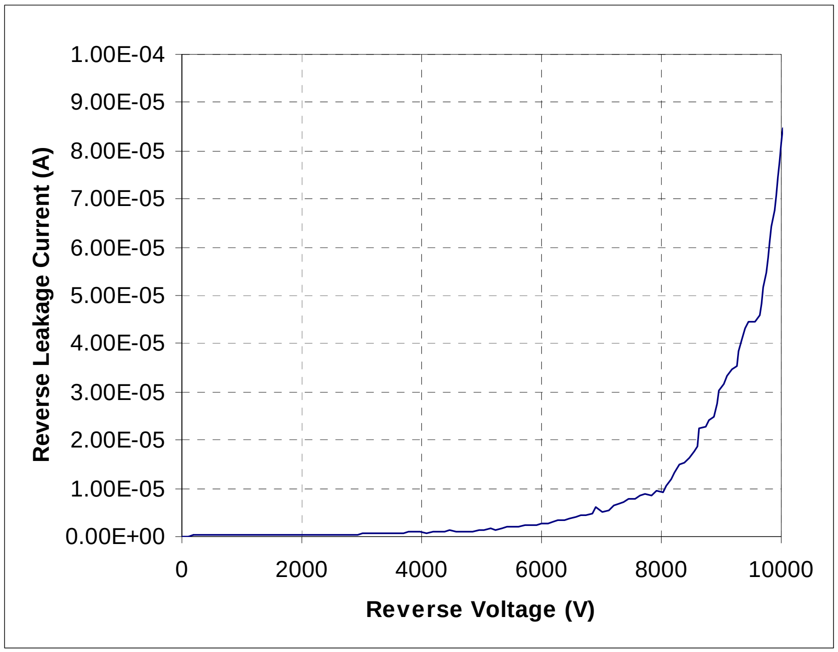


10kV/20A SiC JBS Diode Has Much Smaller Reverse Recovery and Higher Switching Speed Compared to PiN

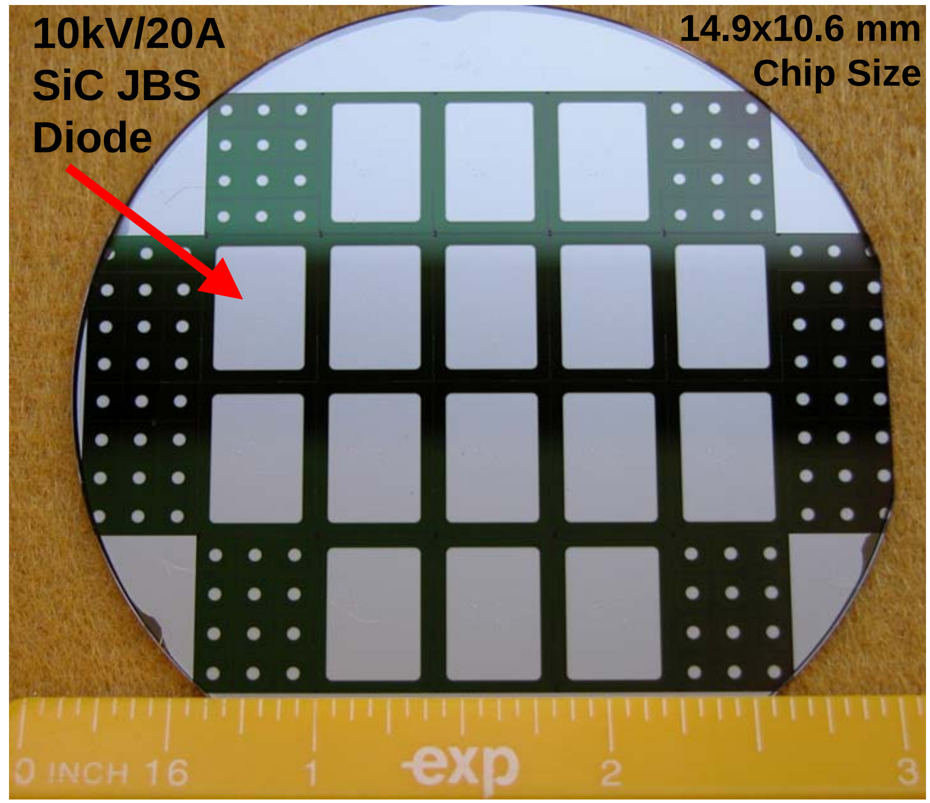
- SiC PiN Reverse Recovery Energy Dissipation still too high for 20 kHz
- Solution - Use SiC Junction Barrier Schottky (JBS) Diodes
- Much Smaller Reverse Recovery (Q_{rr}) and Higher Switching Speed
- HPE-II Refocused on 10kV/20A SiC JBS Diodes
- 10kV/5A SiC JBS Diodes Demonstrated with Single Wafer Blocking Yield > 40%
- Remaining Issue – 10kV SiC JBS Diode Needs to Be Scaled Up to 20A with 30%Yield

10kV/20A SiC JBS Diode Device Characteristics

10kV/20A SiC JBS Diode Yield Up to 37%



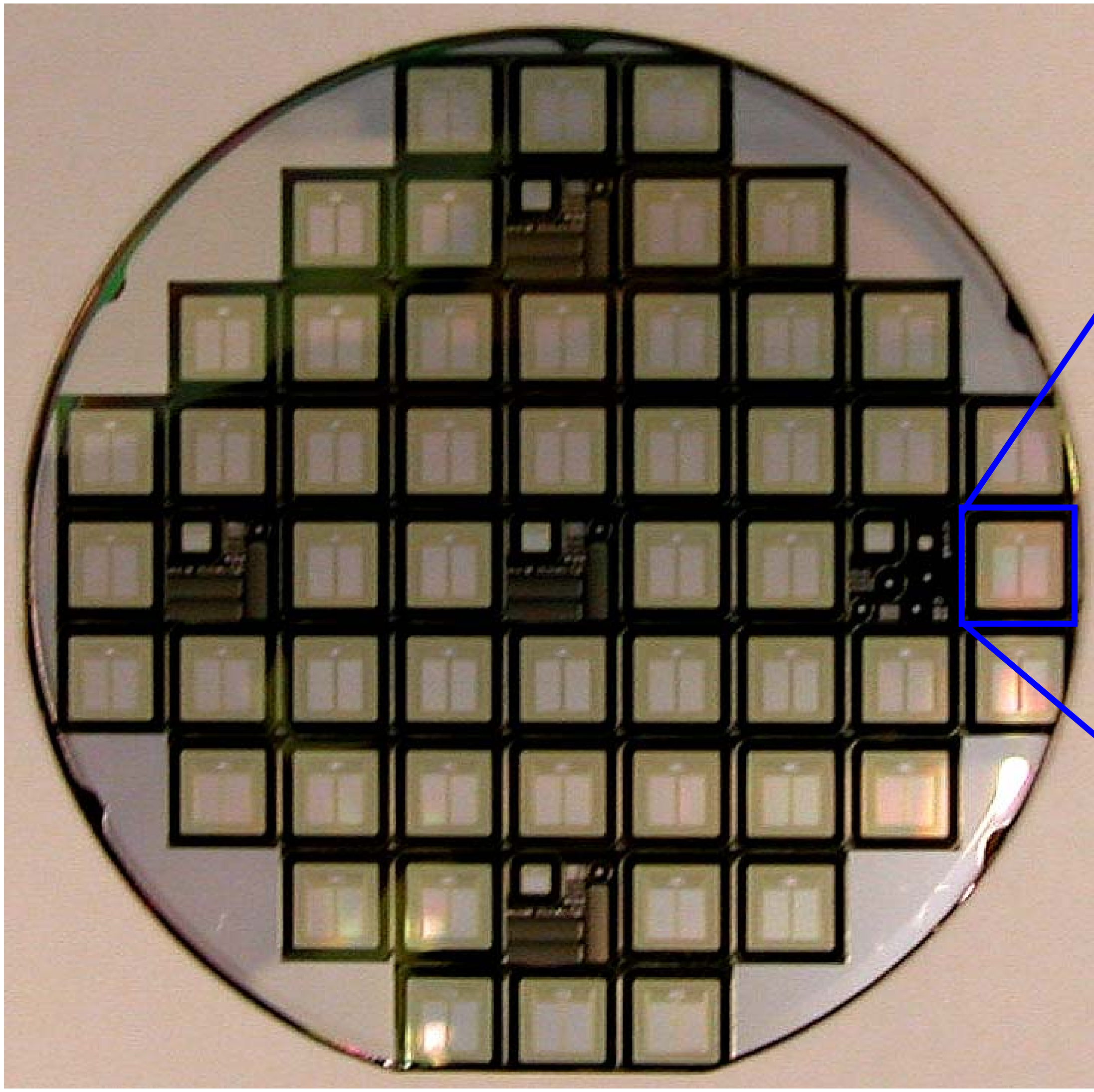
Reverse Blocking of 10kV/20A SiC JBS Diodes



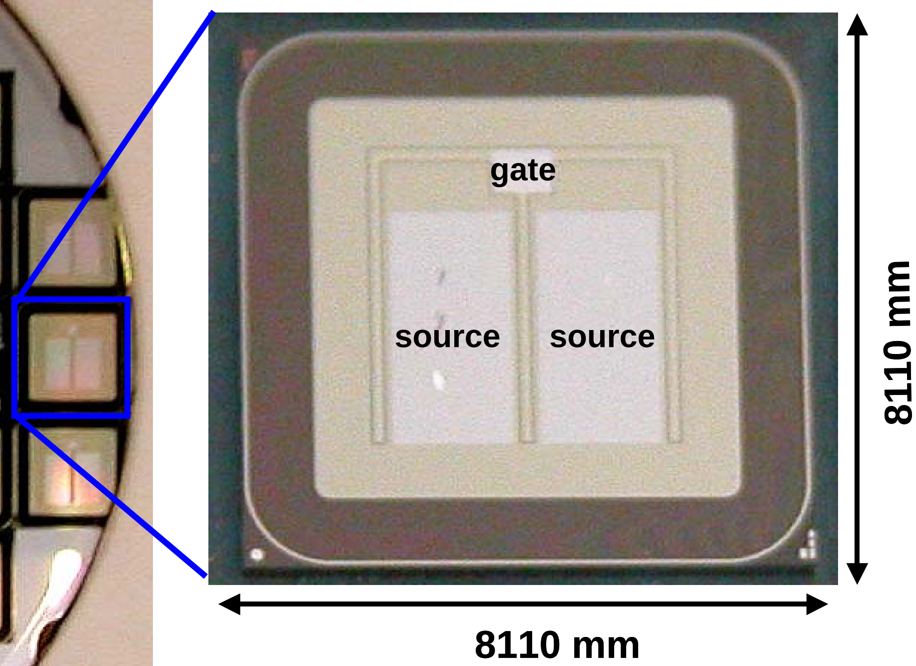
10kV/20A SiC JBS Diodes Fabricated on 3-in 4HN-SiC Wafer

CREE INC

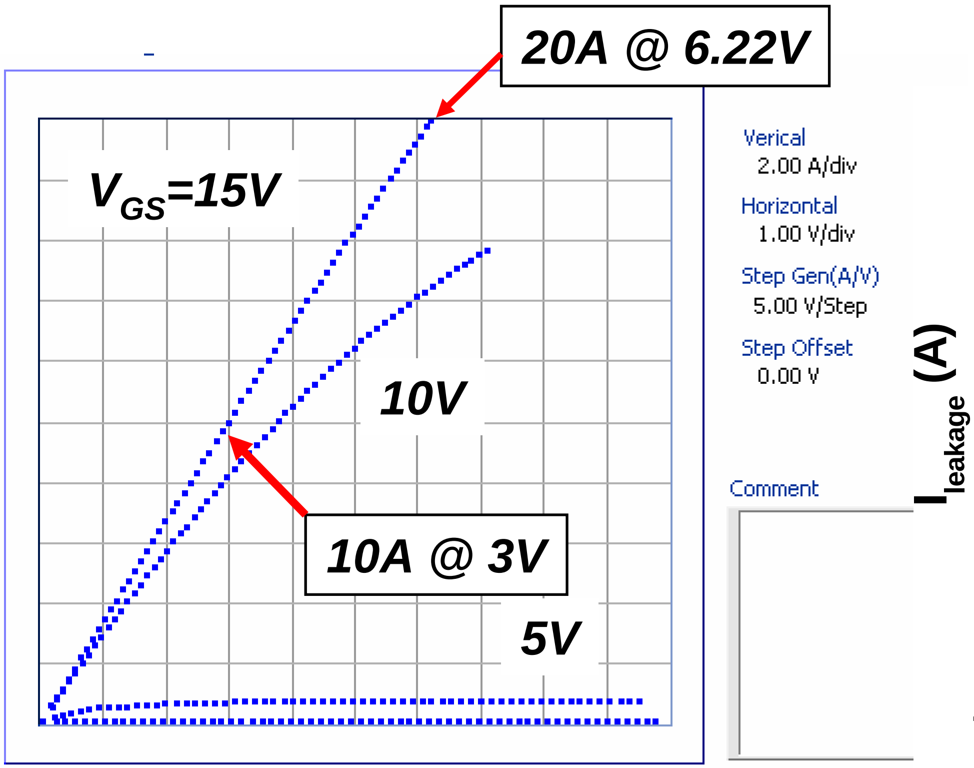
10kV/20A SiC DMOSFET

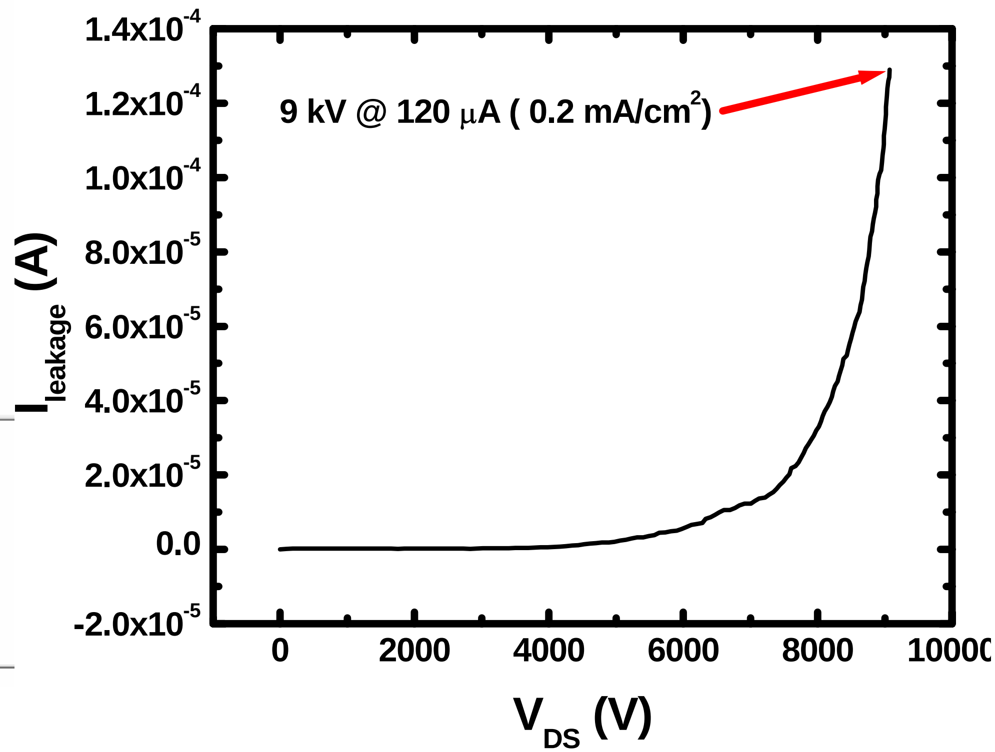


10kV/20A SiC DMOSFETs Fabricated on 3-in 4HN-SiC Wafer



9kV/20A SiC DMOSFET Device Characteristics

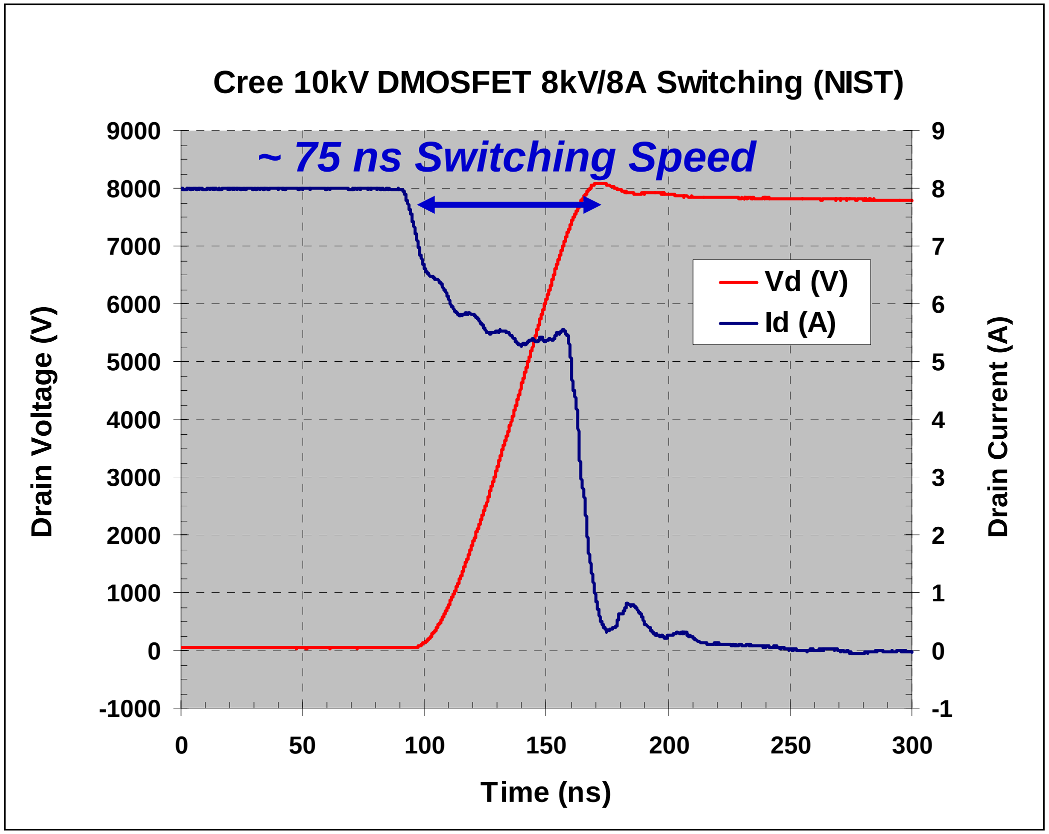




$R_{on,sp}$ = 91 mΩ-cm²
20 A @ 189 W/cm²

BV > 9 kV

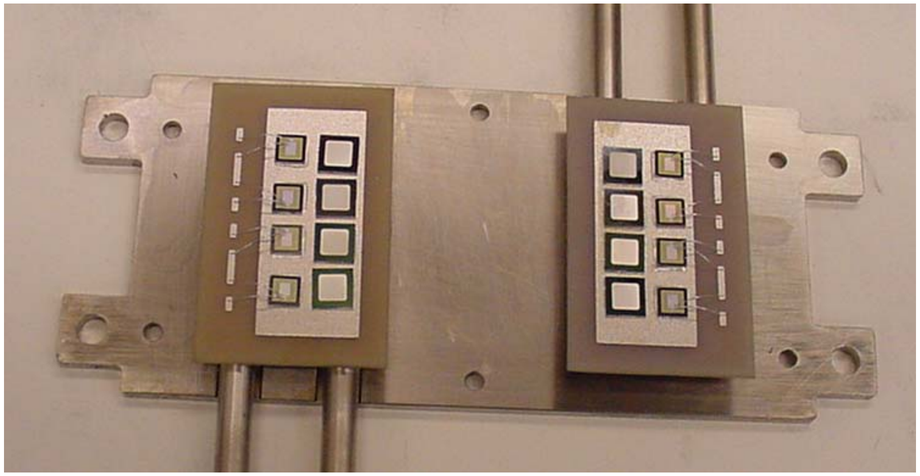
10kV SiC DMOSFET Demonstrated For 20 kHz Switching of SiC Module

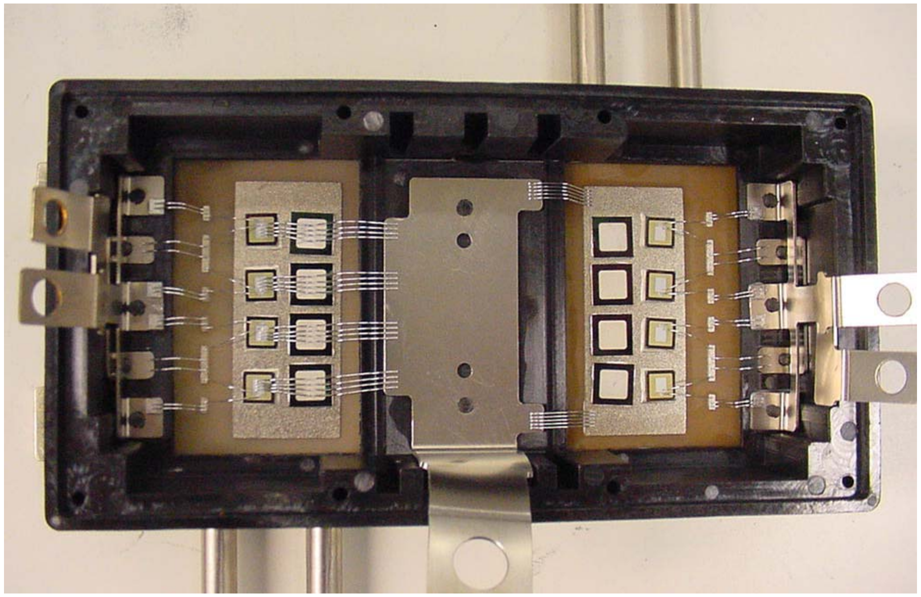


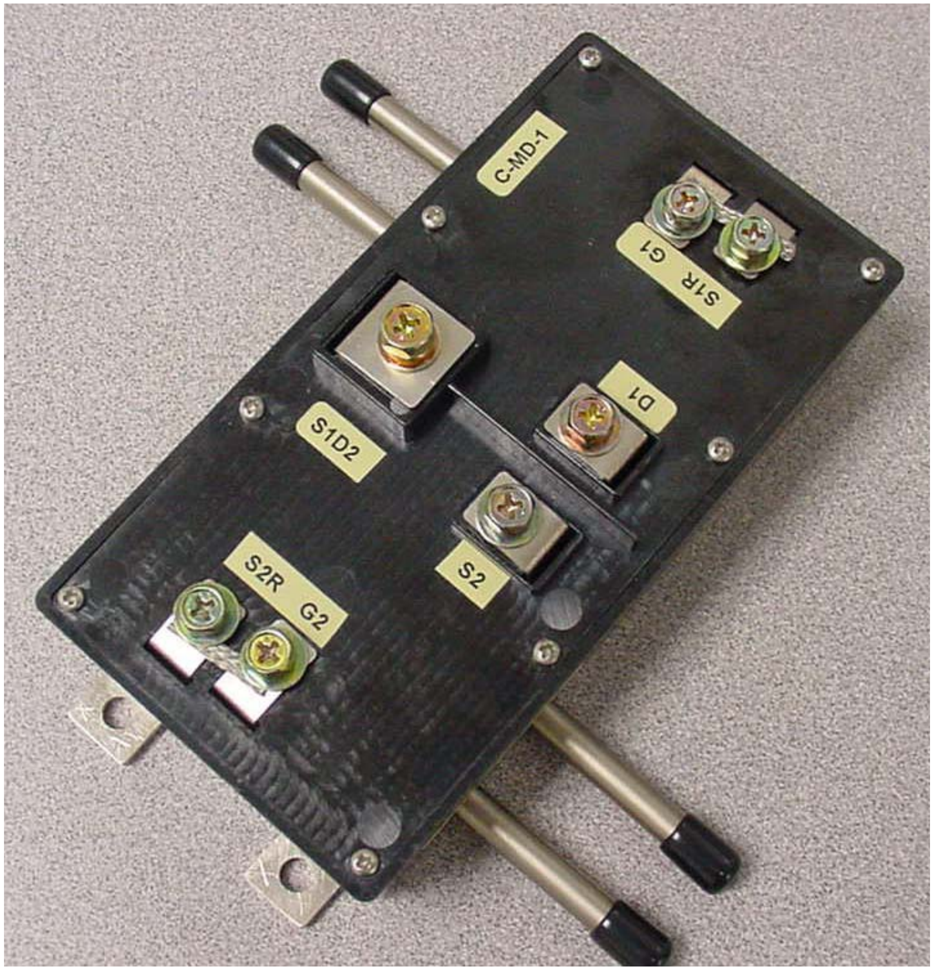
Measured Switching Speed of ~ 75 ns for 10kV SiC DMOSFET at 25°C

- **10kV/10A SiC DMOSFETs Demonstrated**
- **10kV SiC DMOSFETs Capable of T_j = 200°C Operation**
- **10kV SiC DMOSFETs Have Switching Speed ~ 75 ns**
- **Enables 20kHz Switching of 10kV SiC Half H-Bridge Module**
- **Remaining Issue – 10kV SiC DMOSFET Needs to Be Scaled Up to 20A with 30% Yield**

10kV/20A SiC DMOSFET Half H-Bridge Module



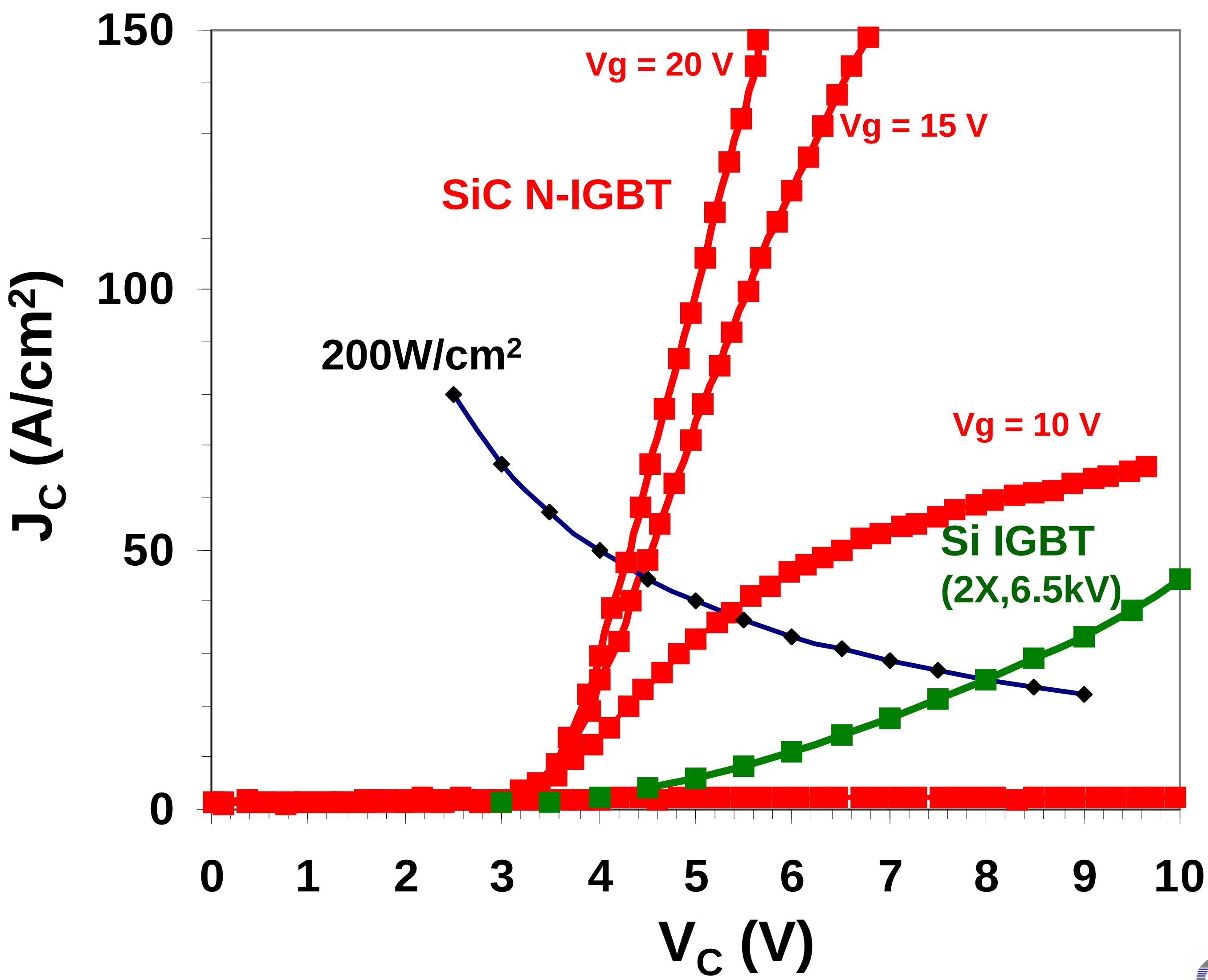




What is next for SiC Power Devices?

- 10 kV pushing upper limit of SiC unipolar devices such as MOSFETs and Schottky diodes
- Higher voltage operation will require minority carrier devices (bipolar)
- The IGBT is the device used in Si for high speed bipolar switching above 1kV
- For SiC, this holds true for >10 kV (10 x the electric breakdown field of silicon)

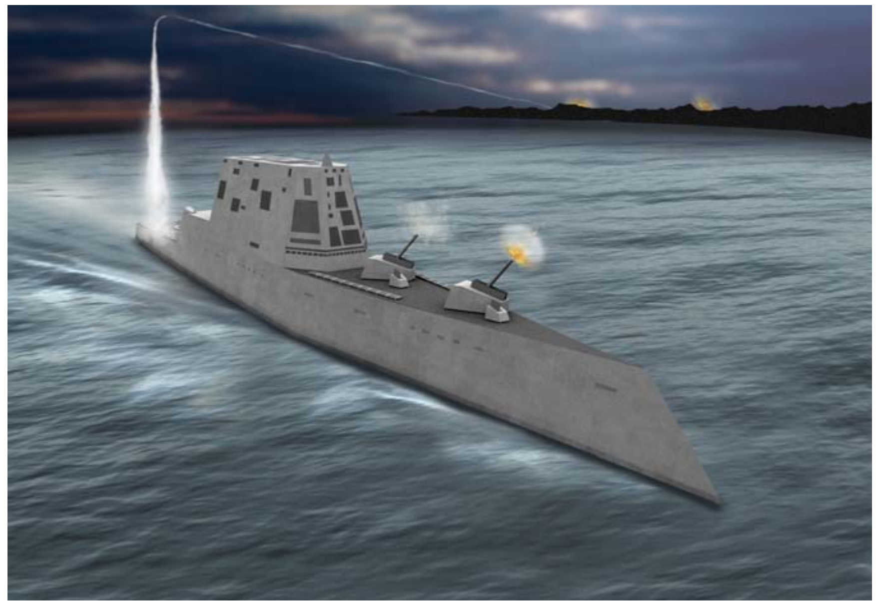
Experimental Results of 12kV SiC N-IGBT and Si IGBT



Applications for SiC IGBTs

15 - 20 kV SiC IGBTs Offer Significant Advantages for Future Combat Vessels Using Electrical Power for Propulsion, Aircraft Launch/Recovery & Weapons Systems

CVN-21



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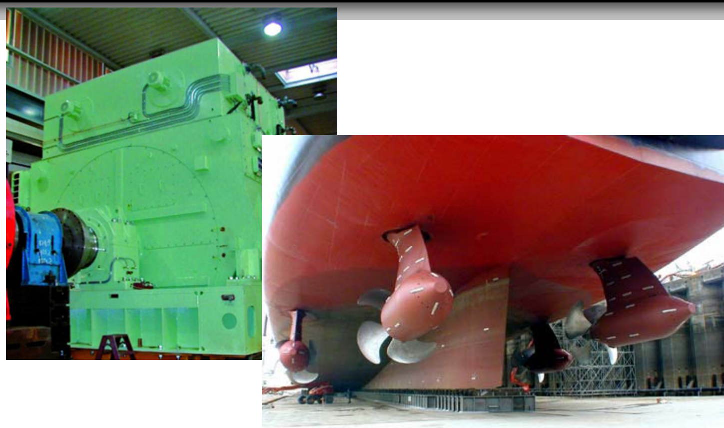
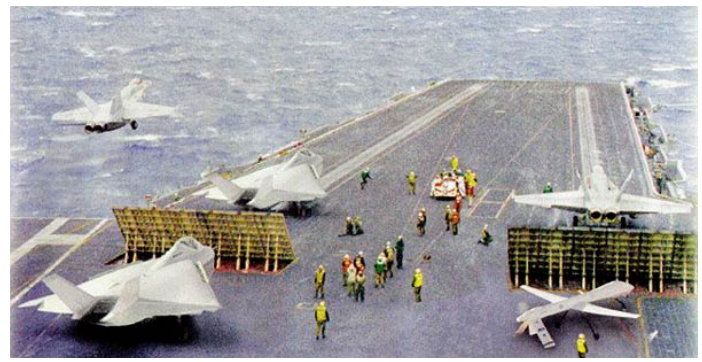
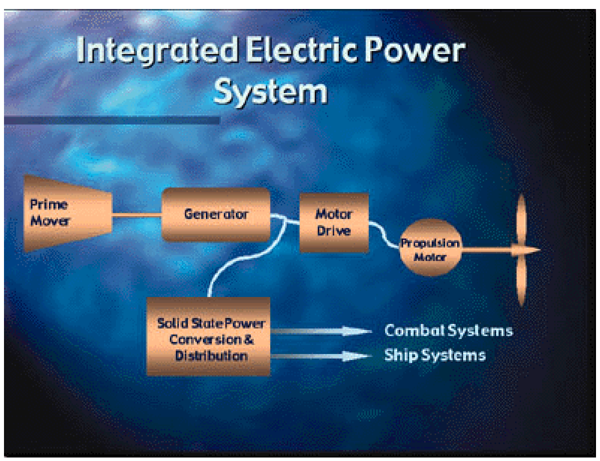
Navy Applications For SiC IGBTs



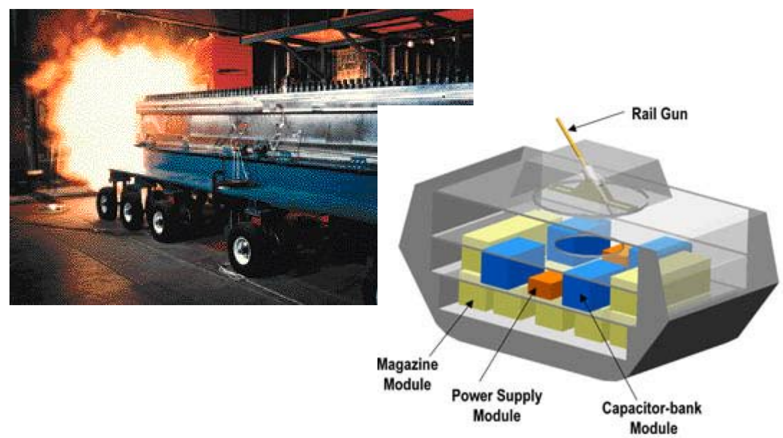
Propulsion
- 4160 V + Motor Drives



Aircraft Launch and Recovery (EMALS)
- 4 kV Motors



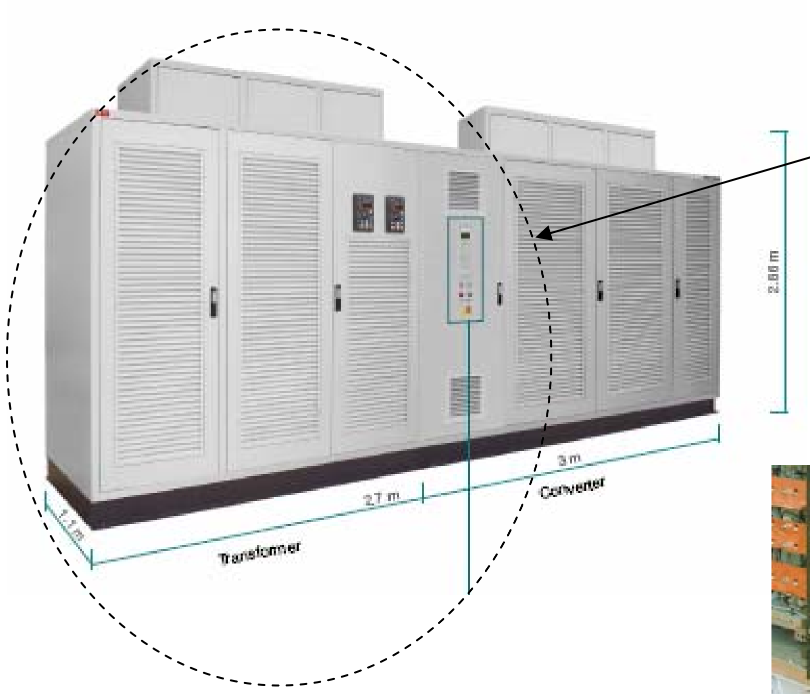
DC Power Distribution
- 6 kV Switchgear



Electromagnetic Gun

Silicon Switch Issues

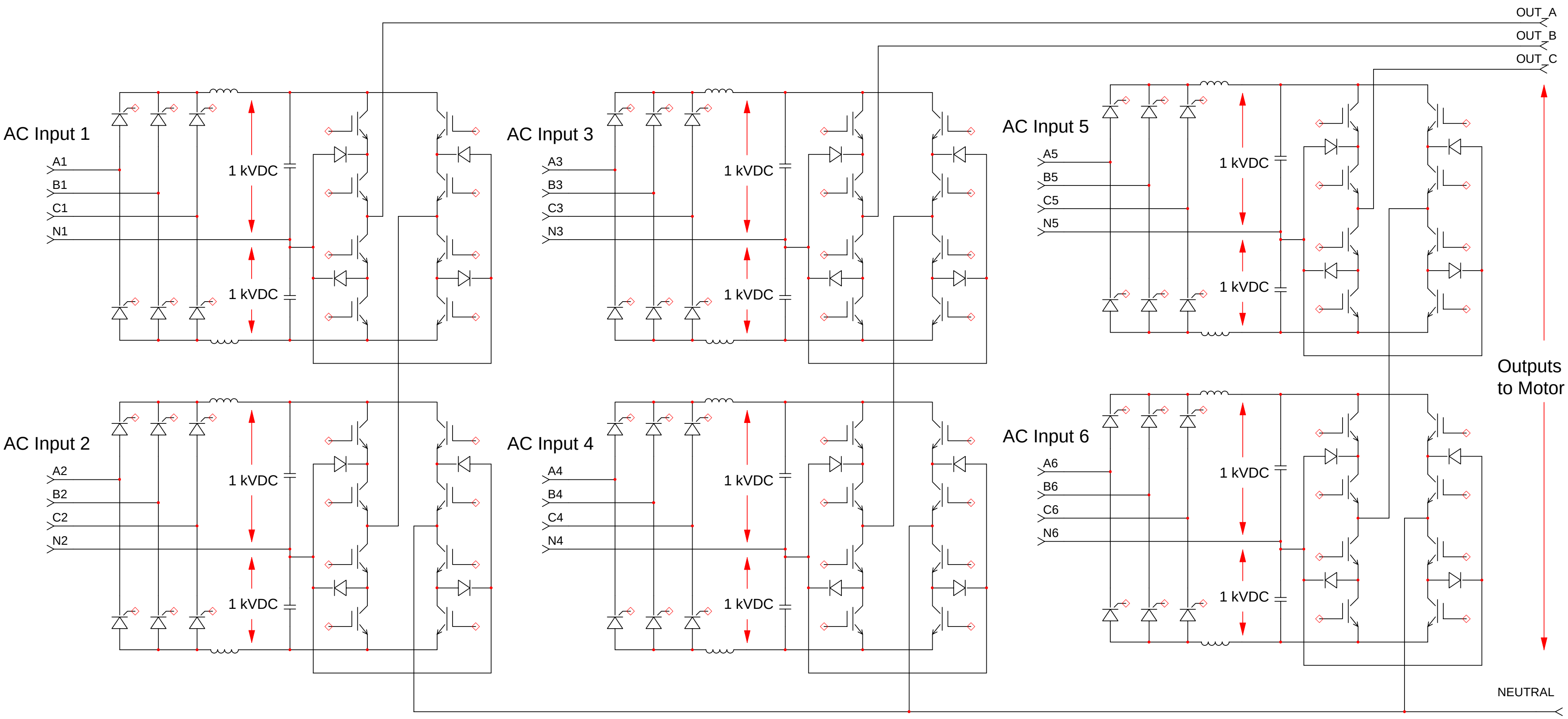
Low Voltage Rating of Silicon Switches Addressed Using Complicated Multi-Level Converters



Multi-level converter requires isolated voltages – large line frequency transformer needed that is almost as big as the converter

Several Si switching devices are required

Cascaded Multilevel Converter Suitable for EMALS Based on Si-IGBTs

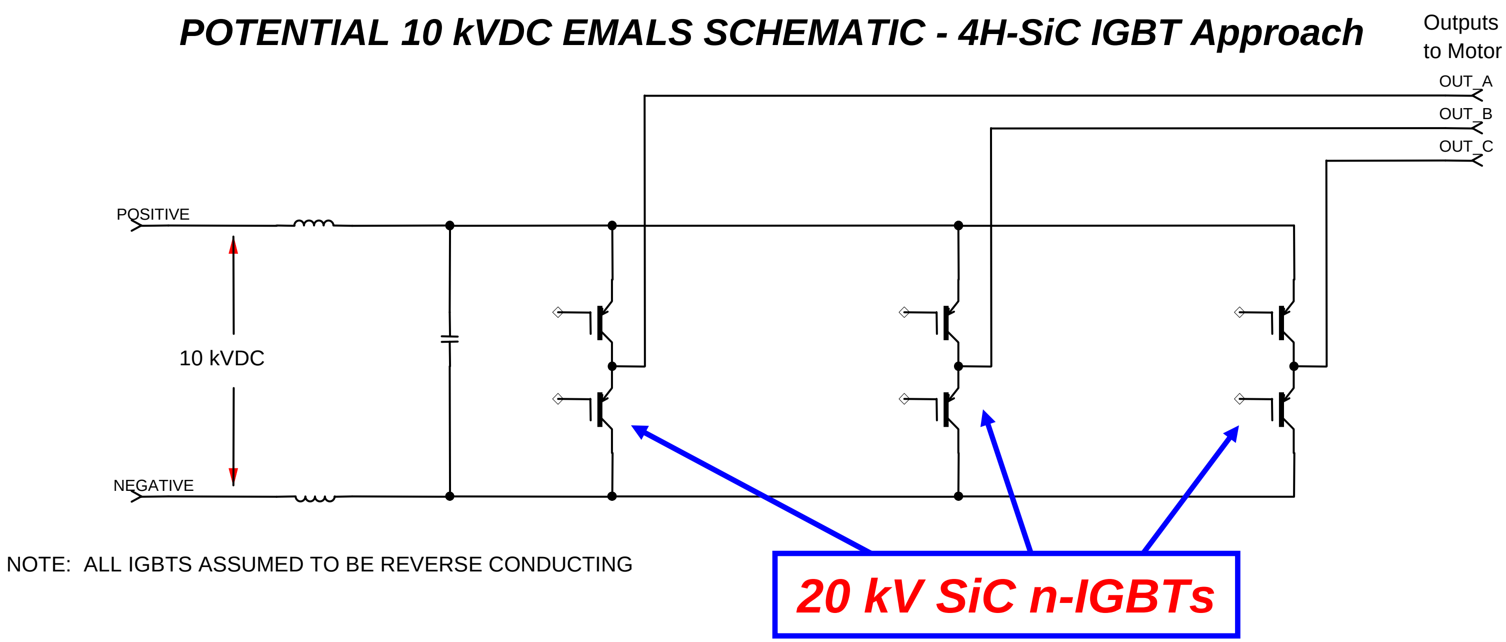


NOTE: ALL IGBTS ASSUMED TO BE REVERSE CONDUCTING

Simplified 2-Level Converter for EMALS Based On 20 kV SiC n-IGBTs

- **20 kV SiC n-IGBTs Used to Implement EMALS Converter Operating from Single Floating 10 kVDC Bus**
- **Results In Significant Reduction in System Complexity**
- **Utilize Simple 3-Phase PWM VSI Topology**
  - **Pulse Width Modulated Voltage Source Inverter Topology**

POTENTIAL 10 kVDC EMALS SCHEMATIC - 4H-SiC IGBT Approach



Summary

- SiC material and device technology has advanced very rapidly under DARPA programs
- MOSFETs and Diodes of unprecedented size and voltage demonstrated
- 150 mm SiC substrates will make large area power devices much more affordable
- 12 kV SiC IGBTs demonstrated with characteristics far superior to silicon
- 15-20 kV SiC IGBTs would offer tremendous benefits for electric propulsion, EMALS, and EM Gun applications in form of size, weight, and efficiency